

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

June 18, 2024

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

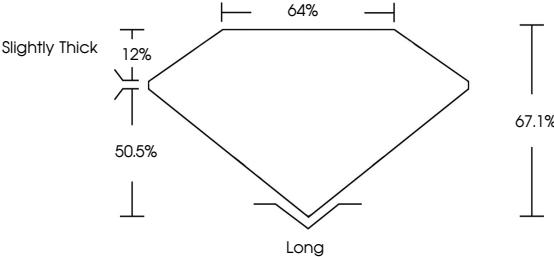
Inscription(s)


Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG638429949

Report verification at [igi.org](#)

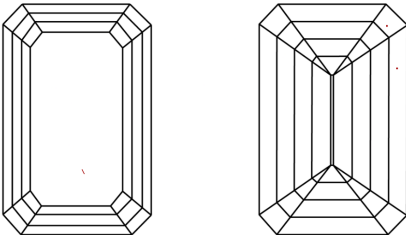
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

IF

VS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Internally Flawless


Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

LABORATORY GROWN DIAMOND REPORT



June 18, 2024

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

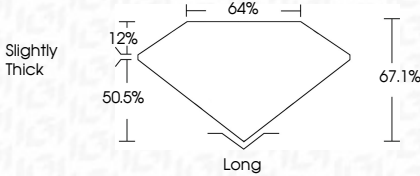
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG638429949

Report verification at [igi.org](#)

PROPORTIONS



IGI

June 18, 2024

IGI Report No LG638429949

EMERALD CUT

6.81 X 4.84 X 3.25 MM

Carat Weight

Color Grade

Clarity Grade

Table

Grade

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.02 CARAT

F

VVS 2

64%

Slightly Thick

Long

EXCELLENT

EXCELLENT



NONE

IGI LG638429949

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.